

## **Chemical Supply List and Location (Cleanroom-2)**

**November 10, 2005**

### **Cabinet #1, Acides**

Acetic acid  
Buffered Oxide Etch (HF) 7:1  
Hydrobromic acid  
Hydrochloric acid  
Hydrofluoric acid  
Nitric acid  
Phosphoric acid  
Sulfuric acid  
Ammonium Fluoride  
Ammonium Hydroxide  
Potassium Hydroxide  
Cyantek CR-7 chrome etch  
Gold etch

### **Cabinet #2, Photoresist, developer, primer and stripper**

Hexamethyldisilazane (HMDS), photoresist primer  
Microposit 1805, 1813, 1818, 1822 photoresist  
LOR 3A  
Microposit photoresist stripper/remover 1165  
Microposit 351, 353, 452 developer  
MF-CD-26, CD-30 developer  
MF-319 developer  
SU-8 developer

### **Cabinet # 3 & 4 (two small cabinet under the table)**

**User storage**

### **Acid Wet Bench, Hydrofluoric acid and wastes**

Buffered Oxide Etch (HF) 7:1  
Hydrofluoric acid  
Ammonium Fluoride

### **Solvent Bench, Solvents**

Acetone  
Methanol  
Isopropyl Alcohol